

**IN THE CLAIMS**

**Please amend the claims as follows:**

Claim 1 (Currently Amended): A method of facilitating a process performed by a semiconductor processing tool, comprising:

inputting process data relating to an actual process being performed by the semiconductor processing tool;

inputting a first principles physical model including a set of computer-encoded differential equations, the first principles physical model describing at least one of a basic physical or chemical attribute of the semiconductor processing tool;

performing first principles simulation for the actual process being performed during performance of the actual process using the physical model to provide a virtual sensor measurement in accordance with the process data relating to the actual process being performed in order to simulate the actual process being performed; and

using the virtual sensor measurement obtained during the performance of the actual process to facilitate the actual process being performed by the semiconductor processing tool.

Claim 2 (Previously Presented): The method of Claim 1, wherein said inputting process data comprises directly inputting the data relating to the actual process being performed by the semiconductor processing tool from at least one of a physical sensor and a metrology tool physically mounted on the semiconductor processing tool.

Claim 3 (Previously Presented): The method of Claim 1, wherein said inputting process data comprises indirectly inputting the data relating to the actual process being performed by the semiconductor processing tool from at least one of a manual input device and a database.

Claim 4 (Original): The method of Claim 3, wherein said indirectly inputting comprises inputting data recorded from a process previously performed by the semiconductor processing tool.

Claim 5 (Original): The method of Claim 3, wherein said indirectly inputting comprises inputting data set by a simulation operator.

Claim 6 (Previously Presented): The method of Claim 1, wherein said inputting process data comprises inputting data relating to at least one of the physical characteristics of the semiconductor processing tool and the semiconductor tool environment.

Claim 7 (Previously Presented): The method of Claim 1, wherein said inputting process data comprises inputting data relating to at least one of a characteristic and a result of a process performed by the semiconductor processing tool.

Claim 8 (Original): The method of Claim 1, wherein said inputting a first principles physical model comprises inputting a spatially resolved model of the geometry of the semiconductor processing tool.

Claim 9 (Original): The method of Claim 1, wherein said inputting a first principles physical model comprises inputting fundamental equations necessary to perform first principles simulation to obtain a virtual sensor reading.

Claim 10 (Original): The method of Claim 1, wherein said performing first principles simulation comprises performing first principles simulation concurrently with the process performed by the semiconductor processing tool.

Claim 11 (Original): The method of Claim 10, further comprising:  
repeatedly updating the data from the physical sensor or metrology tool during the semiconductor process;  
repeatedly performing the first principles simulation using the updated data during the semiconductor process;  
facilitating the semiconductor process concurrently with running the semiconductor process based on virtual sensor measurements obtained during the semiconductor process.

Claim 12 (Original): The method of Claim 10, further comprising:  
setting boundary conditions for the first principles simulation prior to a start of the semiconductor process;  
performing a time dependent simulation of the semiconductor process during the semiconductor process and without direct input from the semiconductor process; and  
facilitating the semiconductor process concurrently with running the semiconductor process based on virtual sensor measurements obtained during the semiconductor process.

Claim 13 (Previously Presented): The method of Claim 1, further comprising performing first principles simulation not concurrently with the process performed by the semiconductor processing tool.

Claim 14 (Original): The method of Claim 13, wherein said inputting data comprises inputting at least one of initial and boundary conditions of said first principles simulation recorded from a process previously performed.

Claim 15 (Original): The method of Claim 3, wherein said indirectly inputting comprises inputting best known input parameters for the physical model.

Claim 16 (Original): The method of Claim 15, further comprising:  
comparing said virtual sensor measurements with actual sensor measurements; and  
refining at least one of the best known input parameters and the physical model to obtain better agreement between the virtual sensor measurements with actual sensor measurements.

Claim 17 (Original): The method of Claim 1, wherein said using the virtual sensor measurement comprises using the virtual sensor measurement to characterize the process performed by the semiconductor processing tool.

Claim 18 (Original): The method of Claim 1, wherein said using the virtual sensor measurement comprises using the virtual sensor measurement to control the process performed by the semiconductor processing tool.

Claim 19 (Original): The method of Claim 1, wherein said using the virtual sensor measurement comprises using the virtual sensor measurement to detect a fault in the process performed by the semiconductor processing tool.

Claim 20 (Original): The method of Claim 1, further comprising storing the virtual sensor measurement in a library for subsequent use in a first principles simulation.

Claim 21 (Currently Amended): The method of Claim 1, further comprising using a network of interconnected resources inside a semiconductor device manufacturing facility to perform ~~at least one of the process steps~~ the first principles simulation recited in Claim 1.

Claim 22 (Original): The method of Claim 21, further comprising using code parallelization among interconnected computational resources to share the computational load of the first principles simulation.

Claim 23 (Original): The method of Claim 21, further comprising sharing simulation information among interconnected resources to facilitate a process performed by the semiconductor processing tool.

Claim 24 (Original): The method of Claim 23, wherein said sharing simulation information comprises distributing simulation results among the interconnected resources to reduce redundant execution of substantially similar first principles simulations by different resources.

Claim 25 (Original): The method of Claim 23, wherein said sharing simulation information comprises distributing model changes among the interconnected resources to reduce redundant refinements of first principles simulations by different resources.

Claim 26 (Currently Amended): The method of Claim 21 1, further comprising using remote resources via a wide area network to facilitate the semiconductor process performed by the semiconductor processing tool.

Claim 27 (Original): The method of Claim 26, wherein said using remote resources comprises using at least one of remote computational and storage resources via a wide area network to facilitate the semiconductor process performed by the semiconductor processing tool.

Claim 28 (Currently Amended): A system comprising:  
a semiconductor processing tool configured to perform a process;  
an input device configured to input data relating to an actual process being performed by the semiconductor processing tool; and

a first principles simulation processor configured to:  
input a first principles physical model including a set of computer-encoded differential equations describing at least one of a basic physical or chemical attribute of the semiconductor processing tool, and

perform first principles simulation for the actual process being performed during performance of the actual process using the physical model to provide a first principles simulation result in accordance with the process data relating to the actual process being performed in order to simulate the actual process being performed to provide a virtual sensor measurement relating to the actual process being performed by the semiconductor processing tool, wherein the virtual sensor measurement obtained during the performance of the actual process is used to facilitate the actual process being performed by the semiconductor processing tool.

Claim 29 (Original): The system of Claim 28, wherein said input device comprises at least one of a physical sensor and a metrology tool physically mounted on the semiconductor processing tool.

Claim 30 (Original): The system of Claim 28, wherein said input device comprises at least one of a manual input device and a database.

Claim 31 (Original): The system of Claim 30, wherein said input device is configured to input data recorded from a process previously performed by the semiconductor processing tool.

Claim 32 (Original): The system of Claim 30, wherein said input device is configured to input data set by a simulation operator.

Claim 33 (Original): The system of Claim 28, wherein said input device is configured to input data relating to at least one of the physical characteristics of the semiconductor processing tool and the semiconductor tool environment.

Claim 34 (Original): The system of Claim 28, wherein said input device is configured to input data relating to at least one of a characteristic and a result of a process performed by the semiconductor processing tool.

Claim 35 (Original): The system of Claim 28, wherein said processor is configured to input a first principles physical model comprising a spatially resolved model of the geometry of the semiconductor processing tool.

Claim 36 (Original): The system of Claim 28, wherein said processor is configured to input a first principles physical model comprising fundamental equations necessary to perform first principles simulation to obtain a virtual sensor reading.

Claim 37 (Original): The system of Claim 28, wherein said processor is configured to perform said first principles simulation concurrently with the process performed by the semiconductor processing tool.

Claim 38 (Original): The system of Claim 37, wherein said processor is further configured to:

repeatedly update the data from the physical sensor or metrology tool during the semiconductor process; and

repeatedly perform the first principles simulation using the updated data during the semiconductor process, wherein the semiconductor process is facilitated concurrently with running the semiconductor process based on virtual sensor measurements obtained during the semiconductor process.

Claim 39 (Original): The system of Claim 37, wherein said processor is further configured to:

set boundary conditions for the first principles simulation prior to a start of the semiconductor process; and

perform a time dependent simulation of the semiconductor process during the semiconductor process and without direct input from the semiconductor process, wherein the semiconductor process is facilitated concurrently with running the semiconductor process based on virtual sensor measurements obtained during the semiconductor process.

Claim 40 (Original): The system of Claim 28, wherein said processor is configured to perform said first principles simulation not concurrently with the process performed by the semiconductor processing tool.

Claim 41 (Original): The system of Claim 40, wherein said processor is configured to perform said first principles simulation at least by using the input data to set at least one of initial and boundary conditions of said first principles simulation recorded from a process previously performed.

Claim 42 (Original): The system of Claim 30, wherein said input device is configured to input best known input parameters for the physical model.

Claim 43 (Original): The system of Claim 42, wherein said processor is configured to:

compare said virtual sensor measurements with actual sensor measurements; and  
refine at least one of the best known input parameters and the physical model to obtain better agreement between the virtual sensor measurements with actual sensor measurements.

Claim 44 (Original): The system of Claim 28, wherein said virtual sensor measurement is used to characterize the process performed by the semiconductor processing tool.

Claim 45 (Original): The system of Claim 28, wherein said virtual sensor measurement is used to control the process performed by the semiconductor processing tool.

Claim 46 (Original): The system of Claim 28, wherein said virtual sensor measurement is used to detect a fault in the process performed by the semiconductor processing tool.

Claim 47 (Original): The system of Claim 28, wherein said processor is further configured to store the virtual sensor measurement in a library for subsequent use in a first principles simulation.

Claim 48 (Currently Amended): The system of Claim 28, further comprising a network of interconnected resources inside a semiconductor device manufacturing facility and connected to said processor and configured to assist said processor in performing at least one of the inputting a first principles simulation model and performing a first principles simulation.

Claim 49 (Original): The system of Claim 48, wherein said network of interconnected resources is configured to use code parallelization with said processor to share the computational load of the first principles simulation.

Claim 50 (Original): The system of Claim 48, wherein said network of interconnected resources is configured to share simulation information with said processor to facilitate said process performed by the semiconductor processing tool.

Claim 51 (Original): The system of Claim 50, wherein said network of interconnected resources is configured to distribute simulation results to said processor to reduce redundant execution of substantially similar first principles simulations.

Claim 52 (Original): The system of Claim 50, wherein said network of interconnected resources is configured to distribute model changes to said processor to reduce redundant refinements of first principles simulations.

Claim 53 (Currently Amended): The system of Claim 48 28, further comprising remote resources connected to said processor via a wide area network and configured to facilitate the semiconductor process performed by the semiconductor processing tool.

Claim 54 (Original): The system of Claim 53, wherein said remote resources comprise at least one of a computational and a storage resource.

Claim 55 (Currently Amended): A system for facilitating a process performed by a semiconductor processing tool, comprising:

means for inputting process data relating to an actual process being performed by the semiconductor processing tool;

means for inputting a first principles physical model including a set of computer-encoded differential equations, the first principles physical model describing at least one of a basic physical or chemical attribute of the semiconductor processing tool;

means for performing first principles simulation for the actual process being performed during performance of the actual process using the physical model to provide a first principles simulation result in accordance with the process data relating to the actual process being performed in order to simulate the actual process being performed; and

means for using the virtual sensor measurement obtained during the performance of the actual process to facilitate the actual process being performed by the semiconductor processing tool.

Claim 56 (Original): The system of Claim 55, wherein said means for performing first principles simulation comprises means for performing first principles simulation concurrently with the process performed by the semiconductor processing tool.

Claim 57 (Original): The system of Claim 56, further comprising:

means for repeatedly updating the data from the physical sensor or metrology tool during the semiconductor process;

means for repeatedly performing the first principles simulation using the updated data during the semiconductor process;

means for facilitating the semiconductor process concurrently with running the semiconductor process based on virtual sensor measurements obtained during the semiconductor process.

Claim 58 (Original): The system of Claim 56, further comprising:

means for setting boundary conditions for the first principles simulation prior to a start of the semiconductor process;

means for performing a time dependent simulation of the semiconductor process during the semiconductor process and without direct input from the semiconductor process; and

means for facilitating the semiconductor process concurrently with running the semiconductor process based on virtual sensor measurements obtained during the semiconductor process.

Claim 59 (Original): The system of Claim 55, further comprising means for inputting best known input parameters for the physical model, said system further comprising:

means for comparing said virtual sensor measurements with actual sensor measurements; and

means for refining at least one of the best known input parameters and the physical model to obtain better agreement between the virtual sensor measurements with actual sensor measurements.

Claim 60 (Original): The system of Claim 55, further comprising means for sharing the computational load of the first principles simulation.

Claim 61 (Currently Amended): The system of Claim ~~[[41]]~~ 55, further comprising means for sharing simulation information among interconnected resources inside a semiconductor device manufacturing facility to facilitate ~~a process~~ the first principles simulation performed by the semiconductor processing tool.

Claim 62 (Currently Amended): A computer readable medium encoded with a computer program containing program instructions for execution on a processor, which when executed by the computer system, cause the processor to perform the steps of:

inputting process data relating to an actual process being performed by the semiconductor processing tool;

inputting a first principles physical model including a set of computer-encoded differential equations, the first principles physical model describing at least one of a basic physical or chemical attribute of the semiconductor processing tool;

performing first principles simulation for the actual process being performed during performance of the actual process using the physical model to provide a first principles simulation result in accordance with the process data relating to the actual process being performed in order to simulate the actual process being performed; and

using the virtual sensor measurement obtained during the performance of the actual process to facilitate the actual process being performed by the semiconductor processing tool.

Claim 63 (Previously Presented): The method of Claim 1, wherein said performing a first principles simulation comprises:

providing for the first principles simulation a reuse of known solutions as initial conditions for the first principles simulation.

Claim 64 (Previously Presented): The system of Claim 28, wherein the first principles simulator is configured to provide for the first principles simulation a reuse of known solutions as initial conditions for the first principles simulation.

Claim 65 (Previously Presented): The system of Claim 55, wherein said means for performing a first principles simulation comprises:

means for providing for the first principles simulation a reuse of known solutions as initial conditions for the first principles simulation.